



Docket No.: M4065.0319/P319
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Ronald A. Weimer, et al.

Application No.: 09/296,835

Group Art Unit: 2813

Filed: April 22, 1999

Examiner: E. Kielin

For: FABRICATION OF DRAM AND OTHER
SEMICONDUCTOR DEVICES WITH AN
INSULATING FILM USING A WET
RAPID THERMAL OXIDATION PROCESS

REQUEST FOR EXTENSION OF TIME

Commissioner for Patents
Washington, DC 20231

Dear Sir:

Applicant hereby petitions for a one month extension of time to and including March 21, 2001 to respond to the Office Action mailed November 21, 2000. Please charge our Deposit Account No. 04-1073 in the amount of \$110.00 covering the fee set forth in 37 CFR 1.17(a)(1).

In the event that a further petition for an extension of time is required to be submitted at this time, applicant hereby petitions under 37 CFR 1.136(a) for an extension of time for as many months as are required to ensure that the above-identified application does not become abandoned.

The Commissioner is hereby authorized to charge any deficiency in the fees filed, asserted to be filed or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Deposit Account No. 04-1073, under Order No. M4065.0319/P319. A duplicate copy of this paper is enclosed.

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T. Flowers

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Dated: March 21, 2001

Respectfully submitted,

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